COURSE GUIDE - short form

Academic year 2017-2018

| Course name ¹ | Vacuum deposition techniques I | | | | Course code | | 5MATAE DI04 | | |
|--------------------------|--------------------------------|-----------------------|----|---------------|-------------|----------|-------------|-------------------------|---|
| Course type ² | DS | Category ³ | DI | Year of study | 5 | Semester | 1 | Number of credit points | 6 |

| Faculty | Materials Scienece and Engineering | Number of teaching and learning hours ⁴ | | | | | |
|----------------|---|--|----|---|----|---|----|
| Field | Materials Engineering | Total | L | Т | LB | Р | IS |
| Specialization | Advanced materials and experimental analysis techniques | 70 | 28 | | 14 | | 28 |

| Pre-requisites from the curriculum ⁵ | Compulsory | - |
|---|-------------|---|
| | Recommended | - |

| General objective ⁶ | Initiating students into knowledge processes in vacuum deposition of thin films. It will deepen the knowledge of the state of vacuum, means for obtaining vacuum, phase transformations, means of obtaining vacuum. |
|------------------------------------|--|
| Specific objectives ⁷ | Identifying the role of vacuum deposition techniques in the field of Materials Engineering. learning and appropriate use of concepts vacuum deposition techniques; Learning theoretical methods, procedures and devices usual deposition of thin films; Learning theoretical methods and means of characterization of thin films deposited in vacuum. |
| Course description ⁸ | Introduction Status vacuum Means of obtaining vacuum Elements of kinetic theory of gases Vacuum thermal evaporation. Ionization of gases and vapors. Physical Basis of magnetron cathode spraying Structure, composition, porosity and adhesion layer deposited by thermal evaporation Spraying. Physical Fundamentals of vacuum thermal evaporation |

| | Assessment | Schedule ⁹ | Percentage of the final grade (minimum grade) ¹⁰ |
|-----------------------|---|-----------------------|---|
| | Class tests along the semester | week 7 | 20% |
| Continuous assessment | Activity during tutorials/laboratory works/projects/practical work | Week1-14 | 30% |
| | Assignments | | |
| | Final assessment form ¹¹ C | | |
| Final assessment | Examination procedures and conditions: 1. theoretical question; open questions of course, conditions: oral; percent of the final grade: 30% 2. theoretical question; open questions of course, conditions: oral; percent of the final grade: 30% 3. theoretical question; open questions in the lab conditions: oral; percent of the final grade: 40% | 50% | |

| Course organizer | Associate Professor, Ph.D. Corăbieru Anişoara | |
|---------------------|---|--|
| Teaching assistants | Associate Professor, Ph.D. Corăbieru Anişoara | |

¹Course name from the curriculum

² DF – fundamental, DID – in the field, DS – specialty, DC – complementary (from the curriculum)

³ DI – imposed, DO –optional, DL – facultative (from the curriculum)

⁴ Points 3.8, 3.5, 3.6a,b,c, 3.7 from the Course guide – extended form (L-lecture, T-tutorial, LB-laboratory works, P-project, IS-individual study)

⁵ According to 4.1 – Pre-requisites - from the Course guide – extended form

⁶ According to 7.1 from the Course guide – extended form

⁷ According to 7.2 from the Course guide – extended form

⁸ Short description of the course, according to point 8 from the Course guide – extended form

 $^{^{9}}$ For continuous assessment: weeks 1-14, for final assessment – colloquium: week 14, for final assessment-exam: exam period

 $^{^{\}rm 10}$ A minimum grade might be imposed for some assessment stages

¹¹ Exam or colloquium